

Microfluidic Thin Film Pressure Balance for the Study of Complex Thin Films

Sébastien Andrieux¹, Pierre Muller¹, Manish Kaushal^{1*}, Nadia Sofía Macias Vera¹, Robin Bollache¹,
Clément Honorez², Alain Cagna³, Wiebke Drenckhan¹

¹Université de Strasbourg, CNRS, Institut Charles Sadron UPR22, F-67000, Strasbourg, France

²Laboratoire de Physique des Solides, CNRS, Université Paris-Saclay, 91405 Orsay, France

³Teclis Scientific, 69380 Civrieux d'Azergues, France

Table 1: Tools used to mill the microfluidic plates, with the parameters for milling. The tools were supplied by *Performance Micro Tool*, except for *, which was purchased from *CIF* (no longer available from this supplier).

| Tool (reference supplier) | Rotation speed (rev/min) | Feed per tooth Fz (mm/rev) | Milled parts |
|---------------------------|--------------------------|----------------------------|---------------------------------|
| TS-2-0781-S | 3209 | 0.00937 | joints and gas channels |
| TS-2-0390-S | 6427 | 0.00468 | liquid channel |
| TS-2-0080-S | 31330 | 0.00096 | bike wheel |
| ET-4-1250-C | 2005 | 0.015 | surfacing and inclined surfaces |
| DU17* (Ø 2mm, 30°) | 3000 | Ø | cones |

* Current address of M.K.: Indian Institute of Technology Kharagpur, Kharagpur-721302, India